



Análisis de recubrimiento / Analysis of covering

PTPAL-2151-1		
SiO ₂	(%)	0,22
Al ₂ O ₃	(%)	0,04
Fe ₂ O ₃	(%)	0,03
MnO	(%)	0,01
MgO	(%)	0,26
CaO	(%)	29,67
Na ₂ O	(%)	0,07
K ₂ O	(%)	0,02
TiO ₂	(%)	0,01
P ₂ O ₅	(%)	0,10
SO ₃	(%)	46,37
As	(ppm)	4,7
Ba	(ppm)	N.D.
Cl	(ppm)	N.D.
Co	(ppm)	N.D.
Cr	(ppm)	N.D.
Cu	(ppm)	N.D.
Ga	(ppm)	7,1
Hf	(ppm)	0,3
La	(ppm)	1,0
Mo	(ppm)	2,2
Nb	(ppm)	15,6
Nd	(ppm)	3,6
Ni	(ppm)	N.D.
Pb	(ppm)	3,5
Rb	(ppm)	15,4
Sc	(ppm)	6,6
Sm	(ppm)	3,2
Sr	(ppm)	882,7
Ta	(ppm)	N.D.
Th	(ppm)	27,6
Tl	(ppm)	0,8
V	(ppm)	N.D.
U	(ppm)	7,4
W	(ppm)	N.D.
Y	(ppm)	17,0
Yb	(ppm)	1,6
Zn	(ppm)	50,3
Zr	(ppm)	31,4
SUMA	(%)	99,11
P.C.	(%)	22,20



Condiciones experimentales / Experimental conditions:

Diámetro de pastilla / pellet diameter: 10 mm

Ánodo / anode: Rh (4 kW)

Colimadores / collimators: 150, 300, 700 μ m

Cristales analizadores / analysing crystals: LIF200, LIF220, PX-10, Ge111, PE002, PX-1

Detectores / Detectors: Flujo y centelleo / flow and scintillation

Presión de cámara / Chamber pressure: < 10 Pa

N.D.: No detectado/ Non detected

P.C.: Pérdida por calcinación / loss on ignition

